Jian Zhang Chen

List of Publications by Year in descending order

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ΙΙΔΝ ΖΗΔΝΟ CHEN

#	Article	IF	CITATIONS
1	Dielectric barrier discharge jet processed TiO ₂ nanoparticle layer for flexible perovskite solar cells. Journal Physics D: Applied Physics, 2022, 55, 034003.	2.8	8
2	Low-Pressure Plasma-Processed Ruthenium/Nickel Foam Electrocatalysts for Hydrogen Evolution Reaction. Materials, 2022, 15, 2603.	2.9	4
3	Facile method to convert petal effect surface to lotus effect surface for superhydrophobic polydimethylsiloxane. Surfaces and Interfaces, 2022, 30, 101901.	3.0	9
4	Comparison between atmospheric-pressure-plasma-jet-processed and furnace-calcined rGO-MnOx nanocomposite electrodes for gel-electrolyte supercapacitors. Journal of Alloys and Compounds, 2022, 911, 165006.	5.5	6
5	Atmospheric pressure plasma jet treatment enhances the effect of Alloy Primer on the bond strength between polymethyl methacrylate and stainless steels: application for retention of magnetic attachment to resin denture base. Colloids and Surfaces B: Biointerfaces, 2021, 197, 111440.	5.0	3
6	Flexible rGO-SnO2 supercapacitors converted from pastes containing SnCl2 liquid precursor using atmospheric-pressure plasma jet. Ceramics International, 2021, 47, 1651-1659.	4.8	13
7	Improved efficiency and air stability of two-dimensional p-i-n inverted perovskite solar cells by Cs doping. RSC Advances, 2021, 11, 20200-20206.	3.6	4
8	Feasibility Study of Dielectric Barrier Discharge Jet-Patterned Perfluorodecyltrichlorosilane-Coated Paper for Biochemical Diagnosis. ECS Journal of Solid State Science and Technology, 2021, 10, 037005.	1.8	4
9	Flexible Complementary Oxide Thin-Film Transistor-Based Inverter With High Gain. IEEE Transactions on Electron Devices, 2021, 68, 1070-1074.	3.0	17
10	Carbon Dioxide Tornado-Type Atmospheric-Pressure-Plasma-Jet-Processed rGO-SnO2 Nanocomposites for Symmetric Supercapacitors. Materials, 2021, 14, 2777.	2.9	9
11	Electropolymerized Poly(3,4-ethylenedioxythiophene)/Screen-Printed Reduced Graphene Oxide–Chitosan Bilayer Electrodes for Flexible Supercapacitors. ACS Omega, 2021, 6, 16455-16464.	3.5	14
12	Characteristics of Graphite Felt Electrodes Treated by Atmospheric Pressure Plasma Jets for an All-Vanadium Redox Flow Battery. Materials, 2021, 14, 3847.	2.9	4
13	Dielectric Barrier Discharge Plasma Jet (DBDjet) Processed Reduced Graphene Oxide/Polypyrrole/Chitosan Nanocomposite Supercapacitors. Polymers, 2021, 13, 3585.	4.5	16
14	The Influence of Helium Dielectric Barrier Discharge Jet (DBDjet) Plasma Treatment on Bathocuproine (BCP) in p-i-n-Structure Perovskite Solar Cells. Polymers, 2021, 13, 4020.	4.5	1
15	Silver mirror reaction metallized chromatography paper for supercapacitor application. Flexible and Printed Electronics, 2021, 6, 045010.	2.7	3
16	East Asian Calligraphy Black Ink-Coated Paper as Flexible Conducting Electrode for Supercapacitor. ECS Journal of Solid State Science and Technology, 2021, 10, 123013.	1.8	1
17	Ar dielectric barrier discharge jet (DBDjet) plasma treatment of reduced graphene oxide (rGO)–polyaniline (PANI)–chitosan (CS) nanocomposite on carbon cloth for supercapacitor application. Energy, Ecology and Environment, 2020, 5, 134-140.	3.9	5
18	Electrochemical and Microstructural Investigations of PtFe Nanocompounds Synthesized by Atmospheric-Pressure Plasma Jet. Journal of the Electrochemical Society, 2020, 167, 056501.	2.9	2

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19	Flexible reduced graphene oxide supercapacitors processed using atmospheric-pressure plasma jet under various temperatures adjusted by flow rate and jet-substrate distance. Materials Research Express, 2020, 7, 015602.	1.6	5
20	Dielectric-Barrier-Discharge Jet Treated Flexible Supercapacitors with Carbon Cloth Current Collectors of Long-Lasting Hydrophilicity. Journal of the Electrochemical Society, 2020, 167, 116511.	2.9	11
21	Concentration effect on properties of Pt-NiOx nanocompounds converted from mixed chloroplatinic acid and nickel acetate precursor films using an atmospheric-pressure plasma jet. Journal of Applied Physics, 2020, 128, 043302.	2.5	2
22	Hydrophilic patterning of octadecyltrichlorosilane (OTS)-coated paper via atmospheric-pressure dielectric-barrier-discharge jet (DBDjet). Cellulose, 2020, 27, 10293-10301.	4.9	6
23	Low Temperature (<40 °C) Atmospheric-Pressure Dielectric-Barrier-Discharge-jet (DBDjet) Plasma Treatment on Jet-Sprayed Silver Nanowires (AgNWs) Electrodes for Fully Solution-Processed n-i-p Structure Perovskite Solar Cells. ECS Journal of Solid State Science and Technology, 2020, 9, 055016.	1.8	6
24	Application of Atmospheric-Pressure-Plasma-Jet Modified Flexible Graphite Sheets in Reduced-Graphene-Oxide/Polyaniline Supercapacitors. Polymers, 2020, 12, 1228.	4.5	3
25	Scanning atmospheric-pressure plasma jet treatment of nickel oxide with peak temperature of â^¼500 °C for fabricating p–i–n structure perovskite solar cells. RSC Advances, 2020, 10, 11166-11172.	3.6	6
26	Low-Temperature (<40 °C) Atmospheric-Pressure Dielectric-Barrier-Discharge-Jet Treatment on Nickel Oxide for p–i–n Structure Perovskite Solar Cells. ACS Omega, 2020, 5, 6082-6089.	3.5	17
27	Plasmas Processes Applied on Metals and Alloys. Metals, 2020, 10, 349.	2.3	0
28	Surface Modification of FeCoNiCr Medium-Entropy Alloy (MEA) Using Octadecyltrichlorosilane and Atmospheric-Pressure Plasma Jet. Polymers, 2020, 12, 788.	4.5	4
29	Influence of mechanical bending strain on bias-stress stability of flexible top-gate p-type SnO TFTs. , 2020, , .		2
30	Atmospheric-pressure surface-diffusion dielectric-barrier discharge (SDDBD) plasma surface modification of PEDOT:PSS. Synthetic Metals, 2019, 256, 116114.	3.9	7
31	Conversion of dense and continuous nickel oxide compound thin films using nitrogen DC-pulse atmospheric-pressure plasma jet. Ceramics International, 2019, 45, 22078-22084.	4.8	6
32	Investigation of ultrashort (< 1Âmin) calcination processes for conversion of Pt–SnOx from mixture of chloroplatinic acid and tin(II) chloride. SN Applied Sciences, 2019, 1, 1.	2.9	0
33	Tyrosinase/Chitosan/Reduced Graphene Oxide Modified Screen-Printed Carbon Electrode for Sensitive and Interference-Free Detection of Dopamine. Applied Sciences (Switzerland), 2019, 9, 622.	2.5	22
34	In-situ atmospheric-pressure dielectric barrier discharge plasma treated CH3NH3PbI3 for perovskite solar cells in regular architecture. Applied Surface Science, 2019, 473, 468-475.	6.1	19
35	Feasibility study of atmospheric-pressure dielectric barrier discharge treatment on CH3NH3PbI3 films for inverted planar perovskite solar cells. Electrochimica Acta, 2019, 293, 1-7.	5.2	20
36	Atmospheric-pressure-plasma-jet processed carbon nanotube (CNT)–reduced graphene oxide (rGO) nanocomposites for gel-electrolyte supercapacitors. RSC Advances, 2018, 8, 2851-2857.	3.6	41

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37	Improved performance of polyaniline/reduced-graphene-oxide supercapacitor using atmospheric-pressure-plasma-jet surface treatment of carbon cloth. Electrochimica Acta, 2018, 260, 391-399.	5.2	58
38	Atmospheric-pressure plasma jet processed Pt/ZnO composites and its application as counter-electrodes for dye-sensitized solar cells. Applied Surface Science, 2018, 436, 690-696.	6.1	24
39	DC-pulse atmospheric-pressure plasma jet and dielectric barrier discharge surface treatments on fluorine-doped tin oxide for perovskite solar cell application. Journal Physics D: Applied Physics, 2018, 51, 025502.	2.8	10
40	Time Evolution Characterization of Atmospheric-Pressure Plasma Jet (APPJ)-Synthesized Pt-SnOx Catalysts. Metals, 2018, 8, 690.	2.3	6
41	Nitrogen DC-pulse atmospheric-pressure-plasma jet (APPJ)-processed reduced graphene oxide (rGO)â€ʿcarbon black (CB) nanocomposite electrodes for supercapacitor applications. Diamond and Related Materials, 2018, 88, 23-31.	3.9	24
42	Scan-Mode Atmospheric-Pressure Plasma Jet Processed Reduced Graphene Oxides for Quasi-Solid-State Gel-Electrolyte Supercapacitors. Coatings, 2018, 8, 52.	2.6	20
43	Low-Temperature-Annealed Reduced Graphene Oxide–Polyaniline Nanocomposites for Supercapacitor Applications. Journal of Electronic Materials, 2018, 47, 3861-3868.	2.2	13
44	Flexible reduced graphene oxide supercapacitor fabricated using a nitrogen dc-pulse atmospheric-pressure plasma jet. Materials Research Express, 2017, 4, 025504.	1.6	22
45	Flexible quasi-solid-state SnO2/CNT supercapacitor processed by a dc-pulse nitrogen atmospheric-pressure plasma jet. Journal of Energy Storage, 2017, 11, 237-241.	8.1	14
46	Screen-printed SnO ₂ /CNT quasi-solid-state gel-electrolyte supercapacitor. Materials Research Express, 2017, 4, 115501.	1.6	16
47	Atmospheric-Pressure Plasma Jet Processed Carbon-Based Electrochemical Sensor Integrated with a 3D-Printed Microfluidic Channel. Journal of the Electrochemical Society, 2017, 164, B534-B541.	2.9	14
48	A Comparison Study of Furnace and Atmospheric-Pressure-Plasma Jet Calcined Pt-Decorated Reduced Graphene Oxides for Dye-Sensitized Solar Cell Application. Journal of the Electrochemical Society, 2017, 164, H931-H935.	2.9	9
49	Application of atmospheric-pressure plasma jet processed carbon nanotubes to liquid and quasi-solid-state gel electrolyte supercapacitors. Applied Surface Science, 2017, 425, 321-328.	6.1	34
50	Atmospheric pressure plasma jet processed reduced graphene oxides for supercapacitor application. Journal of Alloys and Compounds, 2017, 692, 558-562.	5.5	35
51	Surface modification of carbon cloth anodes for microbial fuel cells using atmospheric-pressure plasma jet processed reduced graphene oxides. RSC Advances, 2017, 7, 56433-56439.	3.6	24
52	Atmospheric-Pressure Plasma Jet Processed Pt-Decorated Reduced Graphene Oxides for Counter-Electrodes of Dye-Sensitized Solar Cells. Coatings, 2016, 6, 44.	2.6	25
53	A Photoactivated Gas Detector for Toluene Sensing at Room Temperature Based on New Coral-Like ZnO Nanostructure Arrays. Sensors, 2016, 16, 1820.	3.8	9
54	Rapid atmospheric-pressure-plasma processed nanomaterials for electrochemical energy harvesting and storage devices. , 2016, , .		0

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55	Atmospheric-pressure-plasma-jet sintered nanoporous AlN/CNT composites. Applied Surface Science, 2016, 377, 75-80.	6.1	6
56	Enhancement of gate-bias and current stress stability of P-type SnO thin-film transistors with SiN <inf>x</inf> /HfO <inf>2</inf> passivation layers. , 2016, , .		0
57	SnO2/CNT nanocomposite supercapacitors fabricated using scanning atmospheric-pressure plasma jets. Materials Research Express, 2016, 3, 085002.	1.6	14
58	Feasibility study of surface-modified carbon cloth electrodes using atmospheric pressure plasma jets for microbial fuel cells. Journal of Power Sources, 2016, 336, 99-106.	7.8	56
59	Atmospheric-pressure plasma jet processed SnO2/CNT nanocomposite for supercapacitor application. Ceramics International, 2016, 42, 14287-14291.	4.8	40
60	Atmospheric pressure plasma jet processed nanoporous Fe2O3/CNT composites for supercapacitor application. Journal of Alloys and Compounds, 2016, 676, 469-473.	5.5	48
61	Ultrafast synthesis of carbon-nanotube counter electrodes for dye-sensitized solar cells using an atmospheric-pressure plasma jet. Carbon, 2016, 98, 34-40.	10.3	59
62	Microstructural, electrical, and optical properties of sol–gel derived HfMgZnO thin films. Materials Research Express, 2015, 2, 096402.	1.6	1
63	Rapid Atmospheric-Pressure-Plasma-Jet Processed Porous Materials for Energy Harvesting and Storage Devices. Coatings, 2015, 5, 26-38.	2.6	31
64	Modeling and simulation of heat transfer characteristics of 12-inch wafer on electrostatic chuck. , 2015, , .		1
65	Simulation studies on bipolar electrostatic chucks. , 2015, , .		0
66	Ultrafast synthesis of continuous Au thin films from chloroauric acid solution using an atmospheric pressure plasma jet. RSC Advances, 2015, 5, 99654-99657.	3.6	18
67	Atmospheric-pressure-plasma-jet sintered nanoporous SnO2. Ceramics International, 2015, 41, 5478-5483.	4.8	16
68	UV photocurrent responses of ZnO and MgZnO/ZnO processed by atmospheric pressure plasma jets. Journal of Alloys and Compounds, 2015, 628, 68-74.	5.5	26
69	Ultrafast Atmospheric-Pressure-Plasma-Jet Sintering of Nanoporous TiO ₂ -SnO ₂ Composites with Features Defined by Screen-Printing. ECS Journal of Solid State Science and Technology, 2015, 4, P3020-P3025.	1.8	8
70	Atmospheric-pressure-plasma-jet sintered dual-scale porous TiO 2 using an economically favorable NaCl solution. Journal of Power Sources, 2015, 281, 252-257.	7.8	13
71	Oxidation of sputtered metallic Sn thin films using N ₂ atmospheric pressure plasma jets. Materials Research Express, 2015, 2, 016504.	1.6	2
72	HfZnO/ZnO Heterostructures Fabricated Using Low-Cost Large-Area Compatible Sputtering Processes. Materials Research Society Symposia Proceedings, 2015, 1731, 18.	0.1	0

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73	Optoelectronic properties of infrared rapid-thermal-annealed SnOx thin films. Ceramics International, 2015, 41, 13502-13508.	4.8	8
74	Deposition of ZnO Thin Films by an Atmospheric Pressure Plasma Jet-Assisted Process: The Selection of Precursors. IEEE Transactions on Plasma Science, 2015, 43, 670-674.	1.3	6
75	Atmospheric-pressure-plasma-jet processed nanoporous TiO ₂ photoanodes and Pt counter-electrodes for dye-sensitized solar cells. RSC Advances, 2015, 5, 45662-45667.	3.6	21
76	Nitrogen Atmospheric-Pressure-Plasma-Jet Induced Oxidation of SnOx Thin Films. Plasma Chemistry and Plasma Processing, 2015, 35, 979-991.	2.4	5
77	Influence of Ca/Al Ratio on Properties of Amorphous/Nanocrystalline Cu–Al–Ca–O Thin Films. Journal of the American Ceramic Society, 2015, 98, 125-129.	3.8	13
78	Ultrafast atmospheric-pressure-plasma-jet processed conductive plasma-resistant Y 2 O 3 /carbon-nanotube nanocomposite. Journal of Alloys and Compounds, 2015, 651, 357-362.	5.5	19
79	Influence of rapid-thermal-annealing temperature on properties of rf-sputtered SnOx thin films. Applied Surface Science, 2015, 327, 358-363.	6.1	27
80	All-vanadium redox flow batteries with graphite felt electrodes treated by atmospheric pressure plasma jets. Journal of Power Sources, 2015, 274, 894-898.	7.8	113
81	Plasma-etched nanoporous TiO ₂ using Ag nanoparticle masks: application for photoanodes of dye-sensitized solar cells. Materials Research Express, 2014, 1, 025505.	1.6	5
82	Periodic anti-ring back reflectors for hydrogenated amorphous silicon thin-film solar cells. Optics Express, 2014, 22, A1128.	3.4	9
83	Back Cover: Plasma Process. Polym. 1â^•2014. Plasma Processes and Polymers, 2014, 11, 100-100.	3.0	0
84	Electromechanical properties of MgZnO/ZnO heterostructures on flexible polyimide and stainless steel substrates under flexing. Journal Physics D: Applied Physics, 2014, 47, 255102.	2.8	12
85	Characterization of Hf/Mg co-doped ZnO thin films after thermal treatments. Thin Solid Films, 2014, 570, 457-463.	1.8	2
86	Sol–gel derived amorphous/nanocrystalline MgZnO thin films annealed by atmospheric pressure plasma jets. Ceramics International, 2014, 40, 2707-2715.	4.8	35
87	Deposition of transparent and conductive ZnO films by an atmospheric pressure plasma-jet-assisted process. Thin Solid Films, 2014, 570, 423-428.	1.8	23
88	Effect of Al/Cu ratios on the optical, electrical, and electrochemical properties of Cu–Al–Ca–O thin films. Journal of Alloys and Compounds, 2014, 609, 111-115.	5.5	9
89	Nanohardness, corrosion and protein adsorption properties of CuAlO2 films deposited on 316L stainless steel for biomedical applications. Applied Surface Science, 2014, 289, 455-461.	6.1	20
90	O ₂ /HMDSO-Plasma-Deposited Organic-Inorganic Hybrid Film for Gate Dielectric of MgZnO Thin-Film Transistor. Plasma Processes and Polymers, 2014, 11, 89-95.	3.0	19

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91	Rapid Atmospheric Pressure Plasma Jet Processed Reduced Graphene Oxide Counter Electrodes for Dye-Sensitized Solar Cells. ACS Applied Materials & Interfaces, 2014, 6, 15105-15112.	8.0	71
92	Atmospheric-Pressure-Plasma-Jet Particulate TiO2Scattering Layer Deposition Processes for Dye-Sensitized Solar Cells. ECS Journal of Solid State Science and Technology, 2014, 3, Q177-Q181.	1.8	18
93	Dynamically programmable surface micro-wrinkles on PDMS-SMA composite. Smart Materials and Structures, 2014, 23, 115007.	3.5	7
94	Oxygen-deficient indium tin oxide thin films annealed by atmospheric pressure plasma jets with/without air-quenching. Applied Surface Science, 2014, 292, 213-218.	6.1	35
95	Influence of annealing temperature on properties of room-temperature rf-sputtered CuAlOx:Ca thin films. Thin Solid Films, 2014, 550, 591-594.	1.8	12
96	Electrical, optical, and microstructural properties of sol–gel derived HfZnO thin films. Journal of Alloys and Compounds, 2014, 601, 223-230.	5.5	14
97	Dye-sensitized solar cells with nanoporous TiO2 photoanodes sintered by N2 and air atmospheric pressure plasma jets with/without air-quenching. Journal of Power Sources, 2014, 251, 215-221.	7.8	50
98	Flexible Transparent ZnO:Al/ZnO/CuAlO x :Ca Heterojunction Diodes on Polyethylene Terephthalate Substrates. Journal of Electronic Materials, 2013, 42, 1242-1245.	2.2	24
99	Preparation of nanoporous TiO2 films for DSSC application by a rapid atmospheric pressure plasma jet sintering process. Journal of Power Sources, 2013, 234, 16-22.	7.8	71
100	Effects of drain-bias and ambient on hump formation in the transfer curves of positively gate-biased MgZnO thin film transistors. Thin Solid Films, 2013, 529, 360-363.	1.8	16
101	KrF excimer laser irradiated nanoporous TiO 2 layers for dye-sensitized solar cells: Influence of laser power density. Ceramics International, 2013, 39, 6183-6188.	4.8	12
102	Single-layer organic–inorganic-hybrid thin-film encapsulation for organic solar cells. Journal Physics D: Applied Physics, 2013, 46, 435502.	2.8	16
103	MgZnO/ZnO Heterostructure Field-Effect Transistors Fabricated by RF-Sputtering. ECS Transactions, 2013, 50, 83-93.	0.5	22
104	Transitions of bandgap and built-in stress for sputtered HfZnO thin films after thermal treatments. Journal of Applied Physics, 2013, 114, .	2.5	11
105	The effect of Zn/Sn Ratio on the Electrical Performance of Amorphous ZrZnSnO (ZZTO) Thin Film Transistors by RF Sputtering. ECS Transactions, 2013, 50, 185-189.	0.5	0
106	Influence of Annealing Conditions on the Bias Temperature Stability of MgZnO Thin Film Transistors. ECS Transactions, 2013, 50, 173-178.	0.5	2
107	Atmospheric pressure plasma jet annealed ZnO films for MgZnO/ZnO heterojunctions. Journal Physics D: Applied Physics, 2013, 46, 075202.	2.8	24
108	Multi-layer thermoelectric-temperature-mapping microbial incubator designed for geo-biochemistry applications. Review of Scientific Instruments, 2012, 83, 045116.	1.3	1

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109	Characterization of rf-sputtered HfMgZnO thin films. Materials Research Society Symposia Proceedings, 2012, 1432, 187.	0.1	1
110	Enhanced optical absorption of dye-sensitized solar cells with microcavity-embedded TiO_2 photoanodes. Optics Express, 2012, 20, A168.	3.4	24
111	Bandgap tuning of MgZnO in flexible transparent n+-ZnO:Al/n-MgZnO/p-CuAlOx:Ca diodes on polyethylene terephthalate substrates. Journal of Alloys and Compounds, 2012, 544, 111-114.	5.5	32
112	Two dimensional thermoelectric platforms for thermocapillary droplet actuation. RSC Advances, 2012, 2, 1639-1642.	3.6	11
113	Improved performance of dye-sensitized solar cells with laser-textured nanoporous TiO2 photoanodes. Materials Letters, 2012, 66, 162-164.	2.6	19
114	Phase transitions of room temperature RF-sputtered ZnO/Mg0.4Zn0.6O multilayer thin films after ther thermal annealing. Thin Solid Films, 2012, 520, 1918-1923.	1.8	13
115	Positive Gate-Bias Temperature Stability of RF-Sputtered \$hbox{Mg}_{0.05}hbox{Zn}_{0.95}hbox{O}\$ Active-Layer Thin-Film Transistors. IEEE Transactions on Electron Devices, 2012, 59, 151-158.	3.0	37
116	Electrical properties of modulation-doped rf-sputtered polycrystalline MgZnO/ZnO heterostructures. Journal Physics D: Applied Physics, 2011, 44, 455101.	2.8	24
117	Enhanced Photoelectrochemical Performance of Photoanode Fabricated Using Polystyrene Ball Embedded TiO[sub 2] Pastes. Electrochemical and Solid-State Letters, 2011, 14, B6.	2.2	11
118	Enhanced Thermoelectric Power in Dual-Gated Bilayer Graphene. Physical Review Letters, 2011, 107, 186602.	7.8	74
119	Indium tin oxide sol–gel precursor conversion process using the third harmonics of Nd:YAG laser. Applied Surface Science, 2011, 257, 10042-10044.	6.1	4
120	DC and AC Gate-Bias Stability of Nanocrystalline Silicon Thin-Film Transistors Made on Colorless Polyimide Foil Substrates. Materials Research Society Symposia Proceedings, 2011, 1321, 259.	0.1	0
121	Dye-Sensitized Solar Cell with Photoanode Made with Polystyrene-Ball-Embedded TiO ₂ Pastes. Japanese Journal of Applied Physics, 2011, 50, 06GF09.	1.5	1
122	Negative bias temperature instability of Rf-sputtered Mg _{0.05} Zn _{0.95} O thin film transistors with MgO gate dielectrics. Semiconductor Science and Technology, 2011, 26, 105007.	2.0	13
123	Mobility Enhancement of Polycrystalline MgZnO/ZnO Thin Film Layers With Modulation Doping and Polarization Effects. IEEE Transactions on Electron Devices, 2010, 57, 696-703.	3.0	51
124	The Influence of Electromechanical Stress on the Stability of Nanocrystalline Silicon Thin Film Transistors Made on Colorless Polyimide Foil. ECS Transactions, 2010, 33, 65-69.	0.5	2
125	Two dimensional electron gases in polycrystalline MgZnO/ZnO heterostructures grown by rf-sputtering process. Journal of Applied Physics, 2010, 108, .	2.5	71
126	The Electromechanical Characteristics of ZnO Grown on Poly(ethylene terephthalate) Substrates. Journal of the Electrochemical Society, 2010, 157, H750.	2.9	8

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127	Electromechanical Stability of Flexible Nanocrystalline-Silicon Thin-Film Transistors. IEEE Electron Device Letters, 2010, 31, 222-224.	3.9	4
128	Influences of Polarization Effects in the Electrical Properties of Polycrystalline MgZnO/ZnO Heterostructure. Materials Research Society Symposia Proceedings, 2009, 1201, 90.	0.1	0
129	Effects of electro-mechanical stressing on the electrical characterization of on-plastic a-Si:H thin film transistors. Materials Research Society Symposia Proceedings, 2009, 1153, 1.	0.1	1
130	Mobility Study of Polycrystalline MgZnO/ZnO Thin Film Layers with Monte Carlo Method. , 2009, , .		0
131	PbTiO <inf>3</inf> /P(VDF-TrFE) nanocomposites for flexible skin. , 2008, , .		1
132	Effects of SiN[sub x] Passivation and Gate Metal Roughness on the Performance of On-plastic a-Si:H TFTs. Electrochemical and Solid-State Letters, 2008, 11, H26.	2.2	3
133	An Unsupervised Approach to Cluster Web Search Results Based on Word Sense Communities. , 2008, , .		9
134	Reliability of Active-Matrix Organic Light-Emitting-Diode Arrays With Amorphous Silicon Thin-Film Transistor Backplanes on Clear Plastic. IEEE Electron Device Letters, 2008, 29, 63-66.	3.9	30
135	Temperature and humidity effects on the stability of on-plastic a-Si:H thin film transistors with various conduction channel layer thicknesses. Materials Research Society Symposia Proceedings, 2008, 1066, 1.	0.1	0
136	Abnormal temperature-dependent stability of on-plastic a-Si:H thin film transistors fabricated at 150 °C. Journal of Applied Physics, 2008, 104, 044508.	2.5	11
137	Thermally Actuated Droplet Motion on Chemically Homogeneous, Striated, and Defected Surfaces. , 2008, , .		0
138	Stability of Amorphous Silicon Thin Film Transistors under Prolonged High Compressive Strain. Materials Research Society Symposia Proceedings, 2007, 989, 4.	0.1	6
139	Direct liquid cooling of room-temperature operated quantum cascade lasers. Electronics Letters, 2006, 42, 534.	1.0	7
140	Silver halide fiber-based evanescent-wave liquid droplet sensing with thermoelectrically cooled room temperature mid-infrared quantum cascade lasers. , 2005, 6010, 62.		0
141	Silver halide fiber-based evanescent-wave liquid droplet sensing with room temperature mid-infrared quantum cascade lasers. Optics Express, 2005, 13, 5953.	3.4	22
142	Effect of contact angle hysteresis on thermocapillary droplet actuation. Journal of Applied Physics, 2005, 97, 014906.	2.5	124
143	Capacitive sensing of droplets for microfluidic devices based on thermocapillary actuation. Lab on A Chip, 2004, 4, 473.	6.0	143
144	A study of mixing in thermocapillary flows on micropatterned surfaces. Philosophical Transactions Series A, Mathematical, Physical, and Engineering Sciences, 2004, 362, 1037-1058.	3.4	34

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145	Crystallization temperature and activation energy of rf-sputtered near-equiatomic TiNi and Ti50Ni40Cu10 thin films. Journal of Non-Crystalline Solids, 2001, 288, 159-165.	3.1	53
146	Composition control of r.fsputtered Ti50Ni40Cu10 thin films using optical emission spectroscopy. Thin Solid Films, 2000, 365, 61-66.	1.8	9
147	Crystallization behavior of r.fsputtered TiNi thin films. Thin Solid Films, 1999, 339, 194-199.	1.8	42
148	Chemical machined thin foils of TiNi shape memory alloy. Materials Chemistry and Physics, 1999, 58, 162-165.	4.0	13